

^A Research Group Tailored Optical Materials Münster University of Applied Sciences Stegerwaldstrasse 39, D-48565 Steinfurt Germany

^B German Aerospace Center Institute of Solar Research, Solar Chemical Engineering Linder Höhe, D-51147 Köln, Germany Tailored Optical

DLR

CIW



FH MÜNSTER

FB Chemieingenieurwesen

University of Applied Sciences

Department of Chemical Engineering

Bundesministerium für Bildung und Forschung

GEFÖRDERT VOM

1. Phosphor converted Xe DBD lamps

Xenon excimer discharge lamps rely on the generation and the subsequent decomposition of Xe excimers in a dielectrically hindered discharge, often called "dielectric barrier discharge" or "silent discharge".^[1] Xe Excimers (compound of the words excited and dimer) emit electromagnetic radiation in the VUV region upon relaxation from electronically and vibronically excited states into the unstable dissociative ground state. Xe excimer emission consists of two emission bands peaking at 152 nm (1st continuum, dominant at lower pressure) and 172 nm (2nd continuum, dominant at higher pressure).^[2] The implementation of energy conversion by applying



Fig. 1 Picture and schematic illustration of the set up of a phosphor converted Xe excimer discharge lamp.

inorganic phosphors as a coating promotes the lamp to an efficient Lab application: UV-C/B emitting radiator for use Photochemical reactors in disinfection and POP depletion, - Water treatment R(t) offering several benefits:



- Free from heavy metals like Mercury
- Instant On/Off & pulsed operation possible
- Tailorable spectral output VUV—UV-C/B/A

An YPO₄:Bi comprising Xe excimer lamp operated in H₂O

excitation.

stainless steel metal netting as outer electrode for operation in gaseous media. Phosphor application is as well possible.

- Surface treatment

Fig. 2 Xe excimer discharge lamps for operation in water and air

2. Application in UV induced Disinfection Ultraviolet germicidal irradiation (UVGI) is the fraction of electromagnetic radiation a. which is capable of killing microorganism or inhibiting their ability to reproduce by afficacy Phosphor comprising Xe excimer causing defects within microorganism's DNA photochemically.^[3] For E. coli germicidal discharge lamps can be used as effectiveness of irradiation peaks in the UV-C at around 265 nm. Phosphor conversion **0.8** efficient UV-C/B or VUV light renders Xe excimer discharge lamps suitable sources of UVGI. germicidal sources in disinfection Selection of highly efficient VUV excitable UV-C emitting phosphors 0,6 -The germicidal efficacy typifies a 4,1 3,5 3,1 2,8 2,5 2,3 2,1 1,9 1,8 1,7 1,5 useful tool to evaluate a phosphor 8,3 6,2 5,0 4,1 3,5 3,1 2,8 2,5 2,3 2,1 1,9 1,8 1,7 1,5 photolytic for its disinfection suitability YPO₄:Pr YPO₄:Bi YBO₃:P 0,4 -Exc.: 160 nm Exc.: 160 nm Exc.: 160 nm Em.: 233 nm ermicidal efficiancy (DIN 5031-10): 60.6% ermicidal efficiancy (DIN 5031-10): 45.9% Germicidal efficiancy (DIN 5031-10): 43.8% Photochemical dimerization of relative 0,2 thymine bases by [2+2] cycloaddition Wavelength /nm Wavelength /nm $\lambda_{max}(YPO_4:Pr) = 235 \text{ nm}$ $\lambda_{max}(YPO_4:Pr) = 235 \text{ nm}$ $\lambda_{max}(YPO_4:Bi) = 241 \text{ nm}$ Fig. 3 VUV excitation-, emission- and reflectance spectra of the UV-C emitting phosphors and YPO₄:Pr, YPO₄:Bi and YBO₃:Pr.

The application of certain phosphors or even phosphor blends yields:

- Application adaptable broad bended germicidal active irradiation in the UV-C/B/A range
- Innate Benefits of Xe excimer discharge: Hg free, pulsed op., instant on/off







Fig 5: Degradation of sulfamethoxazole and intermediate products (measured as total organic carbon, TOC) during photolysis and photooxidation (*) using xenon DBD lamps with YPO₄:Bi, YPO₄:Pr in comparison to a standard amalgam lamp; Q_{rad} is the radiant energy per volume of processed aqueous solution.

3. Application in Advanced Oxidation Processes (AOP)

Xenon DBD lamps with YPO_4 :Bi³⁺/Pr³⁺ were tested for the degradation of the antibiotic sulfamethoxazole (20 mg/l).

According to fig. 5 almost complete mineralization is achieved in contrast to standard amalgam lamps when only radiation is applied (photolysis). With additional dosage of hydrogen peroxide (1 equivalent according to chemical oxygen demand) 70% mineralization is achieved with amalgam lamps (photooxidation). Mineralization with YPO_{4} :Bi³⁺/Pr³⁺ lamps is accelerated with hydrogen peroxide.

photolytic mineralization of Radiant energy demand for sulfamethoxazole is 20-60 times higher for only 20% TOC degradation with amalgam lamps in comparison to YPO₄:Bi³⁺/Pr³⁺ lamps (fig. 6).

Degradation of sulfamethoxazole with the photooxidation process requires 10 times more radiant energy with amalgam lamps than with YPO_4 :Bi³⁺/Pr³⁺ lamps for reducing the TOC by only 70% (fig. 6).



Fig 6: Comparison of the required radiant per volume of sulfamethoxazole solution for 20%, 70% and 90 % TOC reduction via photolysis or photooxidation (*) using xenon DBD lamps with YPO₄:Bi, YPO₄:Pr in comparison to a standard amalgam lamp; Q_{rad} is the radiant energy per volume of processed aqueous solution.

4. A Crucial Quality Criterion: Device Lifetime

Most phosphor converted Xe excimer lamps suffer from a fast aging involving dramatic loss of output intensity within a few hundreds of hours of operation. An YPO₄: Bi comprising lamp has lost 30% of its initial intensity after ~230 hours of operation (L70) as demonstrated by figure 5. It was figured out, that the lamp aging phenomenon is governed by aging of the applied phosphor.

Detailed analytical survey of phosphor samples recovered from aged Xe excimer lamps included: VUV-spectroscopy, temperature dependent photoluminescence Spectroscopy, PXRD, ³¹P-NMR, XPS and EPR.

Aging of anYPO₄:Bi³⁺ comprising Xe excimer discharge lamp



Fig. 7 Left: UV-C output vs. run-time for a YPO₄:Bi comprising Xe lamp; Right: Excitation, emission and reflectance spectra of untreated and aged YPO_{4} :Bi (after 700 hrs run-time).

The aging of a phosphor is dependent on the host structure and the introduced activator species. It consists of:

- Colour centre formation which leads to pronounced greying, measurable from 250 800 nm.
- Reduction of P⁵⁺ to P³⁺ when phosphates are applied as host structure, e.g. YPO₄:Bi which leads to the formation of distinct UV-absorption bands and a broad banded emission in the deep red originating from P^{3+} ([Ne]3s² electron configuration).

Measures to prevent aging

- Protective particle coating
- Sophisticated lamp design avoiding phosphor – discharge interaction

Fig. 8 Illustration of UV driven particle coating process [4].

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